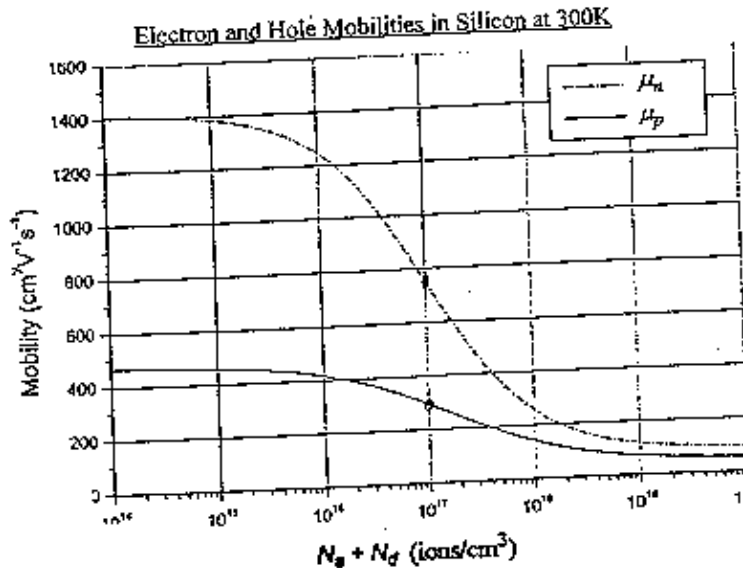


## EE 130 Fall 2000 Midterm 1 Prof. King

INSTRUCTIONS:

1. Use the values of physical constants listed below.
2. SHOW YOUR WORK.
3. Write answers clearly in spaces provided
4. Specify units whenever appropriate.



**Physical Constants**

Description	Symbol	Value
electronic charge	$q$	$1.6 \times 10^{-19}$ C
electron rest mass	$m_0$	$9.1 \times 10^{-31}$ kg
thermal voltage at 300K $kT/q$		0.026 V

**Properties of Silicon at 300K**

Description	Symbol	Value
band gap	$E_g$	1.12 eV
intrinsic carrier density	$n_i$	$10^{10}$ cm <sup>-3</sup>
permittivity	$\epsilon_{Si}$	$1.0 \times 10^{-12}$ F/cm
electron affinity	$\chi_{Si}$	4.05 V

### Problem #1: Semiconductor Fundamentals [20 points]

Consider a silicon sample maintained at 300K under equilibrium conditions, doped with the following impurities:

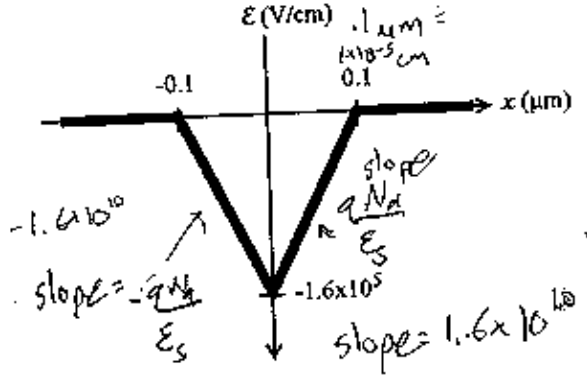
- Phosphorus:  $5 \times 10^{16}$  cm<sup>-3</sup>
- Boron:  $5 \times 10^{16}$  cm<sup>-3</sup>

- a.) What are the carrier mobilities in the sample? [4 pts]  
 $\mu_n$  and  $\mu_p$  = ?
- b.) What are the electron and hole concentrations in the sample? [4 pts]  
 $n$  and  $p$  = ?
- c.) What is the conductivity type of the sample? [2 pts]
- d.) What is the resistivity of the sample? [4 pts]  
 $\rho$  = ?
- e.) What is the mean scattering time for electrons in the sample? [3 pts]  
Assume  $\tau_n = 0.26 \tau_0$ . Note:  $1 \text{ kg-cm}^2/\text{V-s/C} = 10^{-4} \text{ s}$   
 $\tau_n$  = ?

- f.) What is the hole diffusion constant in the sample? [3 pts]  
 $D_p = ?$

**Problem #2: pn Junction: Electrostatics [25 points]**

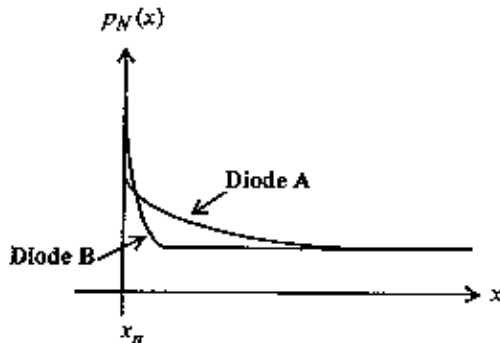
Given the following electric-field distribution inside an ideal Si pn step junction maintained at 300K:



- Sketch the doping profile of this pn junction. [6 pts]  
*{sketch}*
- What is the built-in potential of this junction? [4 pts]  
 Note:  $(kT/q) \ln 10 = 0.060 \text{ V}$  at 300K  
 $\Phi_{bi} = ?$
- What is the applied bias  $V_a$  for the given electric-field distribution? [3 pts]  
 $V_a = ?$
- Sketch the energy-band diagram. Show the positions of the quasi-Fermi levels relative to  $E_i$  and to each other on both sides of the junction. [5 pts]  
*{sketch}*
- What is the junction capacitance at this bias? [3 pts]  
 $C_j = ?$
- Calculate the reverse-bias breakdown voltage, assuming that the critical electric field  $E_{crit}$  is  $5 \times 10^5 \text{ V/cm}$ . [4 pts]  
 $V_b = ?$

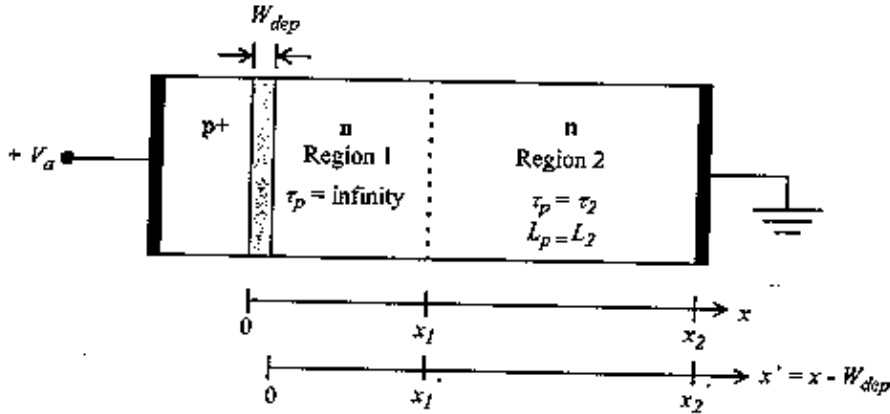
**Problem #3: pn Junctions [35 points]**

- a.) The minority-carrier concentration profiles on the n-side of two ideal Si p+n step-junction diodes maintained at 300K are pictured below:



Check the appropriate boxes in the table below, and provide brief justifications for your answers. [20 pts]

b.) Consider the Si p+n step-junction diode below. The doping on the n-side is uniform, but the minority-carrier lifetime  $\tau_{Ap}$  is infinite in region 1 and has finite value  $\tau_{A2}$  in region 2. Assume that the depletion width  $W_{dep}$  is smaller than  $X_1$ , and that the length of region 2 is much longer than the minority-carrier diffusion length  $L_2$  in region 2.



i.) Write expressions for the excess minority-carrier concentration in region 1 and region 2. [5 pts]

Note: You should express your answers in terms of several position-dependent parameters.

Region 1:  $P_n'(X') = ?$

Region 2:  $P_n'(X') = ?$

ii.) Sketch the excess minority-carrier profile in the quasi-neutral n region under forward bias. Specify the boundary conditions at  $X' = 0, X_1'$  and  $X_2'$ . [10 pts] *{sketch}*

### Problem #4: Metal-Semiconductor Contact [20 points]

Consider an ideal Schottky diode maintained at 300K, made by depositing tungsten ( $\phi_{PSi} = 4.5 \text{ eV}$ ) onto n-type Si.

a.) What is the work function of Si, if  $N_d = 10^{17} \text{ cm}^{-3}$ ? [5 pts]

$\phi_{Si} = ?$

b.) What is the Schottky barrier height? [3 pts]

$\phi_{b,n} = ?$

c.) What is the built-in potential? [3 pts]

$\phi_{bi} = ?$

d.) Draw the equilibrium energy-band diagram of the Schottky diode. Label  $\phi_{PSi}$ ,  $\phi_{Si}$ ,  $\phi_{XSi}$ ,  $\phi_{PHb,n}$ , and  $\phi_{PHbi}$ , as well

as  $E_c$ ,  $E_v$ ,  $E_i$ , and  $E_f$  in the Si. [9 pts]

*{drawing}*

### ANSWERS:

1.) a.)  $\mu_n = 750 \text{ cm}^2/\text{V}\cdot\text{s}$ ,  $\mu_p = 300 \text{ cm}^2/\text{V}\cdot\text{s}$

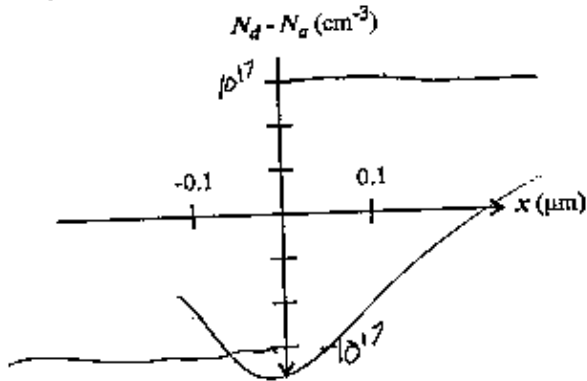
b.)  $n = 10^{10} \text{ cm}^{-3}$ ,  $p = 10^{10} \text{ cm}^{-3}$

c.)  $\sigma = 1.68 \times 10^{-6} \text{ A}/\text{V}\cdot\text{cm}$

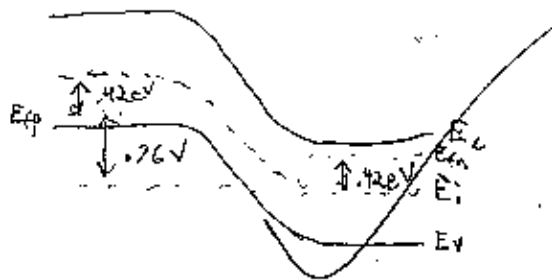
d.)  $\rho = 4.17 \times 10^5 \text{ OHM}\cdot\text{cm}$

- e.)  $\tau_{Umn} = 1.11 \times 10^{-13} \text{ s}$
- f.)  $D_p = 7.8 \text{ cm}^2/\text{s}$

2.) a.)



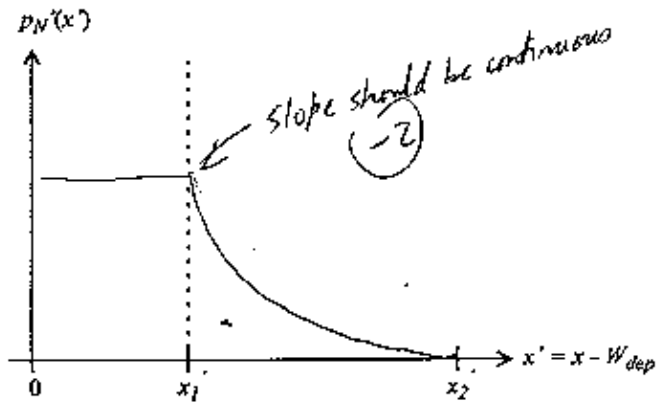
- b.)  $\phi_{bi} = 0.84 \text{ V}$
- c.)  $V_a = -0.76 \text{ V}$
- d.)



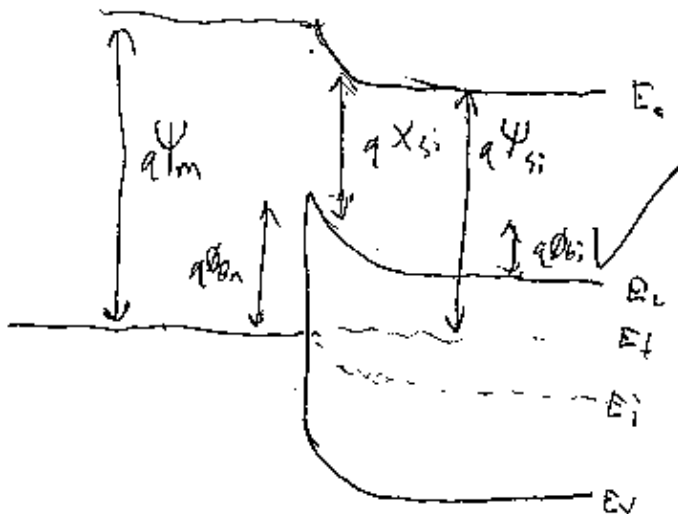
- e.)  $C_j = 5 \times 10^{-8} \text{ F/cm}^2$
- f.)  $V_b = 15.6 \text{ V}$

3.) a.)

- b.) i.) Region 1:  $Pn'(X') =$   
Region 2:  $Pn'(X') =$
- ii.)



- 4.) a.)  $\Psi_{Si} = 4.20 \text{ V}$   
 b.)  $\Phi_{bn} = 0.45 \text{ V}$   
 c.)  $\Phi_{bi} = 0.304 \text{ V}$   
 d.)



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